

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

SUPPRESSION OF LOCALIZED METAL PRECIPITATE
FORMATION AND CORRESPONDING METALLIZATION
DEPLETION IN SEMICONDUCTOR PROCESSING

Application Number :

Confirmation Number:

First Named Applicant: Jonathan Chapple-Sokol

Attorney Docket Number: BUR920040018US1

Art Unit:

Examiner:

Search string: (6596637 or 6319833 or 6197690 or 6177349).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	6596637	2003-07-22	Schonauer et al			
	2	6319833	2001-11-20	Schonauer et al			
	3	6197690	2001-03-06	Schonauer et al			
	4	6177349	2001-01-23	Schonauer et al			

Signature

Examiner Name	Date